A PORTABLE ARC-SEEDED MICROWAVE PLASMA TORCH

§ 0. GOVERNMENT FUNDING

§ 1. BACKGROUND OF THE INVENTION

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§ 1.1 FIELD OF THE INVENTION

The present invention generally concerns atmospheric pressure plasma generation devices (or "plasma sources"). In addition, the present invention also concerns

15   applications for this microwave plasma torch as well as the feasibility of enlarging the device for generating multiple torches simultaneously.

§ 1.2 BACKGROUND

20   Atmospheric pressure plasma sources may be used in applications requiring plasmas to be exposed directly to the open air. The applications include spray coating and materials synthesis (See, e.g., the articles: M. I. Boulos et al., "Thermal Plasma Fundamentals and Applications," Vol. 1, Plenum Press, 1994, pp. 33-47 and 403-418 (hereafter referred to as "the Boulos article"); and "Thermal Plasma Torches and

25   Technologies," Vol. 1, O. P. Solonenko, Ed., Cambridge: Cambridge Int. Sci. Publ., 2001 (hereafter referred to as "the Solonenko article").), microwave reflector/absorber (See, e.g., the articles: R. J. Vidmar, "On the use of atmospheric pressure plasmas as electromagnetic reflectors and absorbers," *IEEE Trans. Plasma Sci.*, Vol. 18, pp. 733-741, 1990 (hereafter referred to as "the Vidmar article"); and E. Koretzky and S. P. Kuo,

30   "Characterization of an atmospheric pressure plasma generated by a plasma torch array," *Phys. Plasmas,* Vol. 5, pp. 3774-3780, 1998 (hereafter referred to as "the Koretzky

article").), shock wave mitigation for sonic boom and wave drag reductions in supersonic flights (See, e.g., the articles: V. P. Gordeev et al., "Plasma technology for reduction of flying vehicle drag," *Fluid Dynamics,* Vol. 31, pp. 313-317, 1996 (hereafter referred to as "the Gordeev article"); S. P. Kuo et al., "Observation of shock wave elimination by a

5 plasma in a Mach-2.5 flow," *Phys. Plasmas,* Vol. 7, pp.1345-1348, 2000 (hereafter referred to as "the Kuo article"); and Daniel Bivolaru and S. P. Kuo, "Observation of supersonic wave mitigation by plasma aero-spike," *Phys. Plasmas,* vol. 9, 721-723, 2002 (hereafter referred to as "the Bivolaru article").), and sterilization and chemical neutralization (See, e.g., the articles: M. Laroussi, "Sterilization of contaminated matter

10 with an atmosphere pressure plasma," *IEEE Trans. Plasma Sci.,* Vol. 24, pp. 1188-1191, 1996 (hereafter referred to as "the Laroussi article"); J. R. Roth et al., "A remote exposure reactor (RER) for plasma processing and sterilization by plasma active species at one atmosphere," *IEEE Trans. Plasma Sci.,* Vol. 28, pp. 56-63, 2000 (hereafter referred to as "the Roth article"); and H. W. Herrmann et al., "Decontamination of

15 chemical and biological warfare (CBW) agents using an atmospheric pressure plasma jet (APPJ)," *Phys. Plasma,* Vol. 6, pp. 2284-2289, 1999 (hereafter referred to as "the Herrmann article").).

Different applications have different requirements on the plasma parameters, such as its density, temperature, volume and flow rate. For spray coating application, a plasma

20 jet is used for heating and acceleration of particles injected into the jet. Thus a high enthalpy jet having large plasma flow rate and density is desirable. Dense, uniform, low temperature, and large volume plasma is desirable for microwave reflector/absorber applications. Used for decontamination of chemical and biological warfare (CBW) agents, a plasma source is aimed at producing chemically active species, such as

25 molecular oxygen in metastable states and atomic oxygen. These reactive species are capable of rapidly destroying a broad spectrum of CBW agents. Some of the applications also favor that the sources can be easily transported.

Dense atmospheric-pressure plasma can be produced through dc/low frequency capacitive or high frequency inductive arc discharges. This technique requires adding gas

30 flows to stabilize the discharges and to carry the generated plasmas out of the discharge regions to form torches. The inductive torch (See, e.g., the article: T. B. Reed,

"Induction-coupled plasma torch", *J. Appl. Phys.*, Vol. 32, pp. 821-824, 1961 (hereafter referred to as "the Reed article").) and non-transferred dc torch (See, e.g., "the Boulos article" and M. Zhukov, "Linear direct current plasma torches", *Thermal Plasma and New Material Technology, Vol. 1: Investigations of Thermal Plasma Generators*, O.

5 Solonenko and M. Zhukov, Ed. Cambridge Interscience Publishing, pp.9-43, 1994, (hereafter referred to as "the Zhukov article").) employ high current power supply and require very high gas flow rate to achieve stable operation. Consequently, the structures of these torches are relatively large and are therefore unsuitable for certain applications.

Torch modules such as those described in the article S. P. Kuo, et al., "Design and

10 electrical characteristics of a modular plasma torch," *IEEE Trans. Plasma Sci.*, vol. 27, no. 3, pp. 752-758, 1999; and U.S. Patent No. 6,329,628 titled "Methods and Apparatus for Generating a Plasma Torch," ("the `628 patent") can be run in dc or low frequency ac mode and can produce low power (hundreds of watts) or high power (a few kW in 60-Hz periodic mode or hundreds of kW in pulsed mode) torch plasmas. However, the size of

15 the torch plasma produced by such modules may be limited by the gap between the electrodes and may depend strongly on the gas flow rate.

In view of the foregoing deficiencies of known plasma torches, there is a need for a plasma source that is portable and that can generate a stable and sizable plasma torch independent of the gas flow rate.

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§ 2. SUMMARY OF THE INVENTION

Embodiments consistent with the present invention meet the aforementioned goals by providing a seeded microwave torch employing a tapered rectangular cavity and

25 moderate microwave power (e.g., time average power of 700 W). A torch module such as one of those described in the `628 patent may be used to generate the seeding plasma, which initiates and controls the location of microwave discharge. With seeding, a low Q cavity (e.g., with a value less than 30) can be used. Thus, a relatively large exit opening on a cavity wall can be used to increase the diameter of the torch. Although the Q-factor

30 of the cavity is reduced, the evanescent microwave electric field can also reach farther out of the cavity opening. Therefore, this new type arc/microwave hybrid plasma torch

does not need gas flow in its operation and yet can produce sizable plasma outside the cavity. Although gas flow is not required, the torch module is flexible in that gas flow may be introduced to its operation. Gas flow can increase the size as well as the energy of the torch plasma. The whole system can be integrated into a portable unit, which

5   permits it to be used in many applications requiring the plasma sources to be easily transported.

The components of an exemplary plasma torch consistent with the present invention may include 1) a microwave source, (e.g., a magnetron) 2) a tapered microwave cavity, 3) a torch module, and 4) a power supply to run the torch module and

10   magnetron. This microwave plasma torch may have a radius of about 1.25 cm or more, a height of about 5 cm, and a peak electron density exceeding $5 \times 10^{13} \text{cm}^{-3}$. This plasma source can easily and quickly start the plasma generation.

A plasma torch device consistent with of the present invention may be easily expanded to an array of torches. This may be done by increasing the length of a narrow

15   section of the cavity and adding, at a quarter wavelength apart, exit opening-torch module pairs on the top and bottom walls of the cavity, respectively. The available microwave power is increased proportionally.

The present invention is attractive because at least some embodiments consistent with the present invention can use electrical circuitry that is simple and is adaptable to a

20   number of AC power sources, such as 60 Hz (or 50 Hz) voltage available at most common wall outlets. In some embodiments consistent with the present invention, such as in aircraft applications, a 400Hz AC power source may be used. This plasma source can run continuously without needing water-cooling and can produce a plasma torch having its cycle energy (in 60 Hz) exceeding 10 J/per cycle, which is large enough for

25   many applications.

The present invention is attractive also because at least some embodiments consistent with the present invention produce an abundance of reactive atomic oxygen, which may be used in applications for rapidly destroying a broad spectrum of chemical and biological warfare (CBW) agents.

In addition, microwave plasma torches, in accordance with the present invention may be used in applications for absorbing radar pulses, e.g., microwave plasma torches arranged in an array on the surface of an aircraft may be used for evading radar detection.

In some embodiments, the tapered microwave cavity is formed by tapering a

5   section of a rectangular waveguide and terminating two ends of the waveguide with conducting plates. In such an embodiment, using a tapered rectangular cavity, the dimensions of the cavity may be varied, as long as the cavity supports a TE_{10n} mode at the selected microwave source frequency, where n is a positive integer ≥ 3.

In some embodiments consistent with the present invention, the height of the

10   narrow section of the cavity is small, e.g., as small as 5 mm, the two ends of the taper section are located at electric field minimum locations of the TE_{10n} mode selected, and the openings in the narrow section to host the torch module and to exit the arc/microwave plasma are located at field maximum locations of the TE_{10n} mode.

In some embodiments, the length of the narrow section of the cavity is $m\lambda_z/2$,

15   where λ_z is the wavelength of the TE_{10n} mode in the axial direction of the cavity, and m is an integer determined by the number of torches to be hosted.

§ 3. BRIEF DESCRIPTION OF THE DRAWINGS

20   Figures 1A-1C are schematic drawings of the top view, side view and bottom view, respectively, of a tapered cavity made in accordance with the present invention.

Figure 2A is a schematic drawing of an arrangement showing a torch module plugged through the plenum chamber to the bottom opening in the taper section of a cavity. Figure 2B is a photograph showing a torch module to be plugged into a cavity.

25   Figure 3 is a microwave electric field distribution measured on the bottom wall of a cavity.

Figure 4 is a circuit diagram of the power supply of the torch device.

Figures 5A to 5C are photos of three microwave torches, one without flow, another with very low airflow (e.g., 1.133 l/s), and a third with a large exit opening and

30   airflow rate, generated by a torch device.

Figures 6A and 6B are schematic drawings of the top view and side view, respectively, of a prolonged tapered cavity, which hosts two torches.

Figures 7A and 7B are images of two seeding plasma torches generated simultaneously by two torch modules placed at the bottom wall of the prolonged narrow section of a rectangular tapered cavity, and two microwave plasma torches generated simultaneously by this enlarged invented torch device, respectively.

Figure 8 is the radial distribution of the electron density $N_e(r)$ near a cavity wall, determined by the emission spectroscopy of a torch.

Figure 9 includes plots of the dependency of intensity on the air-flow rate f of relative intensities I_R of spectral lines - Fe I (385.991 nm), Cu I (809.263 nm), Cu II (766.47 nm), and O I (777.194 nm) at the location approximately 1"(2.5 cm) away from the nozzle exit of the torch module.

Figure 10 is a plot of V-I characteristics of an arc discharge and magnetron input.

Figure 11 is a plot of power functions of the arc discharge and magnetron input.

Figure 12 is a plot of dependency of cycle energies of an arc discharge and magnetron input on gas flow rate f.

§ 4. DETAILED DESCRIPTION

The present invention involves novel methods and apparatus for generating a microwave plasma torch. The following description is presented to enable one skilled in the art to make and use the invention, and is provided in the context of particular applications and their requirements. Various modifications to the disclosed embodiments will be apparent to those skilled in the art, and the general principles set forth below may be applied to other embodiments and applications. Thus, the present invention is not intended to be limited to the embodiments shown.

In the following, functions, which may be performed by the present invention, are introduced in § 4.1. Then, structures of the apparatus built in accordance with the present invention are described in § 4.2. Thereafter, operations of the apparatus are described in § 4.3. Finally, conclusions about the present invention are presented in § 4.4.

§ 4.1 FUNCTIONS

The present invention may be used to generate a microwave plasma torch having a relatively large size (e.g., at least 5 cm height and at least 2 cm wide) and a relatively

5   high density (e.g., at least 10^{13} electrons/cm^3). The present invention may also be used to generate a plasma torch that does not need a gas flow for its operation and having enhanced enthalpy and stability. The present invention may be considered as a unit of a microwave plasma torch and several units in an array may be installed in a single cavity with prolonged narrow section to host all units. The present invention may use one or

10   more units of microwave plasma torches in applications for spray coating and materials synthesis, for decontamination of CBW agents, and for absorbing radiation (e.g., radar).

§ 4.2 STRUCTURES

15   In the following, a new portable microwave plasma torch is described in § 4.2.1. Thereafter, systems with one or more units of the microwave plasma torches described in § 4.2.1 are described in § 4.2.2.

§ 4.2.1 A PORTABLE ARC-SEEDED MICROWAVE PLASMA
20   TORCH

A new hybrid arc/microwave torch will be described with reference to Figures 1A-1C. The tapered cavity of the torch device may be constructed in accordance with the dimensions described below.

25   The end cross section (110) of the un-tapered section (106) may be the same as that of a standard S-band (WR-284) waveguide. (e.g., ~ 7.2 cm x 3.4 cm). The S-band rectangular waveguide is tapered to a smaller cross section (e.g., 7.2 cm × 0.5 cm). The two sides of the waveguide (100) are terminated by conducting plates to form a cavity. This cavity includes three sections. Sections I (106) and III (105) on the two sides of the

30   waveguide (100) have uniform cross sections. The wider section I (106) may have a length (103) of $3\lambda_z/8$ (e.g., ~ 8.74 cm) and the narrow section III (105) may have a length (111) of $\lambda_z/2$ (e.g., ~ 11.65 cm). The tapered middle transition section II (104) may have

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the same width as the adjoining sections (e.g., ~7.2cm), may have a height ranging from ~ 3.4 cm to ~ 0.5 cm, may have a length of λ_z /2 (e.g., ~11.65 cm) and a slope angle θ $\cong \tan^{-1}(2.9/11.65) \cong 14^0$.

Microwave generated by a magnetron (e.g., 2.45 GHz, 700 W) radiates into this

5   cavity at opening (108). The opening (108) may be located at about quarter wavelength ($\lambda_0/4$) (more precisely, $\lambda_z/8$) away from the open-end of section I of the cavity. Thus, if $\lambda_0 = 12.25$ cm is the free space wavelength and $\lambda_z = \lambda_0/[1 - (\lambda_0/2a)^2]^{1/2} = 23.3$ cm is the axial wavelength for the TE_{103} mode, and if a = 7.2 cm is the dimension of the wider side of the cross section, the quarter wavelength in the axial direction of the cavity may be

10   5.83 cm and the total axial length of the cavity may be 32 cm $\cong 1.5 \, \lambda_z$.

At the maximum wave electric field location in the narrow section III (105) of the cavity, which may be $\lambda_z/4 = 5.83$ cm away from its shorted-end, two aligned openings (109 and 102) on the bottom (107) and top (101) walls, respectively, are introduced. Both openings have the same diameter of 1.3 cm.

15   A gas plenum chamber (206), such as those described below, is aligned to the openings (109 and 102) and attached (e.g., welded) to the bottom wall (107) of the narrow section III (105) of the cavity (100). Gas plenum chamber (206) is used to feed the gas flow through as well as to host the torch module generating the seeding plasma.

Referring to Figure 2A, a torch module (204), such as those described in detail in

20   the Kuo article or the '628 patent, is then screwed into this plenum chamber (206) to the bottom opening (109), as shown schematically in Figure 2A (only part of the narrow section III (105) of the cavity is shown). The top opening (102) allows the plasma to stream out of the cavity. As further shown in Figure 2A, the plenum chamber (206) may include a gas inlet port (207), and the torch module (204) may include openings (208) on

25   the frame (210) of the torch module to fluidly couple the gas plenum chamber (206) with the annular gas chamber (209) of the module, a (e.g., tungsten) central electrode (201), a (e.g., ceramic) insulator (202), a sealing washer (205), and a holder (203) to hold the insulator to the frame (210) of the module. The upper corner of the transition section may be set at $\lambda_z/2$ away from the shorted-end of the narrow section III to prevent the

30   possibility of microwave discharge at that location. Using half wavelength as the

transition length of the taper minimizes the impact of nonuniformity on the cavity mode. Figure 2B is a photograph (250) showing a torch module to be plugged into a cavity.

Figure 3 illustrates a spatial distribution of the microwave electric field normal to the bottom wall of a cavity as measured by a small monopole antenna. The antenna was made of an insulated wire of 1 mm diameter and 4 mm long, which was connected to the central line of a 50 Ω coaxial line. To carry out the measurements, the bottom wall of the cavity was replaced by a perforated screen having uniform distributed openings of 2 mm diameter and separated by about 6.7 mm. Thus, the antenna could be inserted into the cavity through the openings of the screen wall. It measured the electric field component perpendicular to the wall, which is the electric field direction of interest and is also the anticipated field direction of the TE_{103} mode. A spectrum analyzer recorded the signal collected by the antenna. As shown, the field intensity at the designated torch location is enhanced by about 15 dB (i.e., from ~-22.5 to ~-7.5).

Figure 4 is a schematic of a power supply and electric circuit (400) that may be used in the torch device to light the torch module (410) and to run the magnetron (420) simultaneously. A single power transformer (430) (e.g., with a turns ratio of 1:25) may be used to step up the 60-Hz line voltage of 120 V (rms) to 3 kV (rms), which is applied to both devices (410 and 420) through serially connected two 1 μF capacitors (442, 444), one for each device. The magnetron (420) is then connected in parallel with a diode (e.g., 15 kV and 750 mA rating) (452) which eliminates the undesirable ohmic loss by preventing negative voltage to be applied between anode and cathode. Although the torch module (410) can be run without diode (454) to generate torch plasma in both half cycles, in the illustrated embodiment it (410) is connected in parallel to serially connected diode (454) and resistor (e.g., 750 Ω) (460) so that it is lit only when microwave is available. This added circuit also increases the voltage applied to the torch module (410) when the diode (454) is reverse biased. This makes it easy to initiate the discharge without increasing the turns ratio of the transformer (430). The discharge evolves quickly to a high current/low voltage diffused-arc mode. The series resistor (460) added in the circuit of the torch module (410) may be used to protect the diode (454) when it is forward biased, by preventing the charging current of the capacitor (444) from exceeding the specification of the diode (454). A reduction of the capacitor charging during this period

also delays the arc discharge. This may be necessary if the magnetron (420) has a higher starting voltage, which will often be the case. The optimal operation condition is when the discharge pulse and microwave pulse overlap each other. Since the discharge pulse may likely be shorter than the microwave pulse and since the microwave field may likely

5   be too low to initiate discharge by itself, it may be desirable to have the arc discharge produce seeding charges right at the beginning of the microwave pulse. The microwave electric field may be parallel to the torch column. In this case, it is effective in moving the torch plasma out of the cavity and enhancing its height.

This torch may be operated without applying a gas flow to stabilize the arc

10   discharge and a large portion of microwave plasma may still be generated outside the cavity. Figure 5A is a photo of a torch generated under a no gas flow condition. As shown, a sizable torch plasma (height of about 1.5 cm and a volume of about 3.5 cc) outside of the cavity is generated. Figure 5B is a photo of an enlarged torch that results when a very small airflow (about 1.133 l/s) is introduced through the torch module. As

15   shown, such a small airflow can significantly increase the height (to about 3.5 cm) and the volume (to about 8 cc) of the torch plasma. The size of this microwave torch plasma increases with the flow rate, microwave power, and the diameter of the exit opening on the cavity wall. Figure 5C shows that the torch plasma may achieve a height more than 6 cm outside the cavity by simply increasing the diameter of the exit opening to 2.5 cm.

20   However, the microwave leakage may also exceed the standard safety level of 5 mW/cm^2, which may be undesirable for some applications.

The tapered rectangular cavity used in this torch device needs a special design consideration. Other parts may be constructed using components from available spark plugs for the torch module (See, e.g., "the Kuo article and patent"), from available

25   microwave oven for the magnetron, transformer, diodes, and capacitors.

Having described a portable setup of an exemplary microwave plasma torch, a second setup having more than one unit of microwave plasma torches is now described in § 4.2.2 below.

§ 4.2.2 SYSTEMS WITH ONE OR MORE ARC-SEEDED MICROWAVE PLASMA TORCHES

Figures 6A and 6B are schematic drawings of a top view and a side view,

5   respectively, of a cavity 600 that can host two torches. The units of the dimensions shown in Figures 6A and 6B is in centimeter (cm). The cavity 600 may be constructed in accordance with the exemplary dimensions provided below. Two pairs of aligned openings 612, 614 are introduced on the top and bottom walls in the narrow section II of the cavity. The diameters of the openings on the top wall 614 a, b (e.g., about 2.5 cm)

10   may be larger than those 612 a, b (about 1.3 cm) of the bottom wall. Two torch modules (not shown) may be attached to the cavity through the bottom openings 612 a, b and the produced torch plasmas may exit the cavity through the two top openings 614 a, b. Two separate power supplies (e.g., such as the one shown in Figure 4) maybe used to run the torch modules. Thus the arc discharges can simultaneously synchronize with the 60 Hz

15   microwave pulse, introduced through opening 608, generated by a magnetron which is run by an identical power supply also shown in Figure 4. Figure 7A is a photo of two arc torches generated by a device, made in accordance with the schematic drawing in Figure 6, in the absence of microwave. The portion of the torches inside the cavity is 1 cm, which is the height of the narrow section of this cavity. Thus each arc torch has a height

20   of about 2.5 cm, which is small because the backpressure of the module is only about 1.2 atm. Figure 7B illustrates the generation of two microwave torches, (i.e., magnetron is switched on) by this device. The height of each microwave torch increases considerably to more than 7 cm. The applied (time averaged) microwave power is about 1.4 kW.

The narrow section of the cavity can be easily extended to host more than one

25   torch. A large volume atmospheric pressure plasma can thus be generated. It can be used to absorb radiation (and therefore provide a cloaking feature) and to decontaminate CBW agents.

The operations of the systems described in this section will be described in § 4.3 below. First, however, a number of applications of these systems are described in § 4.2.3

30   below.

§ 4.2.3 EXEMPLARY APPLICATIONS OF SYSTEM

There are a number of potential applications from an arrangement of one or more microwave plasma torches. As described in § 4.2.3.1 below, a system made in accordance

5   with the present invention, such as those described in § 4.2.1, may be used to generate plasma jet carrying reactive species such as atomic oxygen. Such as a plasma jet may be used to decontaminate chemical and biological warfare (CBW) agents. As described in § 4.2.3.2 below, a system including an array of microwave plasma torches, made in accordance with the present invention, such as those described in § 4.2.2, may be used to

10   absorb radiation for radar cloaking. This application may be applied to systems aboard an aircraft, such as a military aircraft for example.

§ 4.2.3.1 DECONTAMINATION OF CBW AGENTS

15   The emission spectroscopy of the microwave plasma torch generated by the embodiment of the present invention described in § 4.2.1 was analyzed to deduce the information on the electron density distribution and composition of torch species. Electron density was evaluated from the Stark broadening of H_β at 486.133 nm and H_α at 656.279 nm. The radial distribution of electron density $N_e(r)$ in the region close to the

20   cavity wall is presented in Figure 8. Electrons in this region close to the cavity wall were shown to distribute quite uniformly across the core of the torch with a peak (in time) density of about $6 \times 10^{13} cm^{-3}$ in the center and of about $7 \times 10^{13} cm^{-3}$ in the boundary layer, which is about 5 mm from the center. Figure 9 shows the dependence on the air-flow rate f of relative intensities of spectral lines -- Fe I (385.991 nm), Cu I (809.263 nm), Cu II

25   (766.47 nm), and O I (777.194 nm) --at boundary layers of the torch, approximately 25 mm away from the nozzle exit of the torch module (i.e., about 20 mm away from the cavity wall). Four flow rate dependent regimes of the torch operation can be easily distinguished. First is the very low flow-rate regime characterized by low excitation and low oxygen content. Second is the low flow rate regime characterized by rapid increase

30   of excitation and relatively high oxygen content. Third is the moderate flow rate regime characterized by increasing excitation of ion lines, and decreasing excitation of atomic

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lines including oxygen. Fourth is relatively high flow rate regime characterized by atomic oxygen lines dominating the emission spectrum. The reactive atomic oxygen has been shown to be capable of rapidly destroying a broad spectrum of CBW agents.

The present invention is portable and operates stably with all-air discharge, which

5   are the advantageous features for decontamination applications.

§ 4.2.3.2   ABSORBING RADIATION FOR RADAR CLOAKING

10   A plasma torch generated by a torch module such as those described in the Kuo article and the '628 patent can have a plasma density of 10^{13} electrons/cm^3 and can attenuate 10 GHz CW microwave by more than 10 dB. The size of each torch is enlarged considerably when microwave is added as shown in Figure 7B. Moreover, the electron density of the microwave plasma torch, as presented in Figure 8 is much higher than that

15   of the arc torch generated by the torch module alone and the absorbing rate of air plasma on radar pulse increases linearly with the electron density. Thus the microwave plasma torch generated by the present invention may be used to improve the effectiveness of radiation absorption considerably. Moreover, devices consistent with the present invention can be run stably with very low gas flow rate and yet can produce a torch with

20   a size larger than that of an arc torch. The microwave plasma torches can also be arranged in an array on the surface of an aircraft for evading radar detection (also referred to as "cloaking").

§ 4.3 OPERATIONS OF AN EXEMPLARY EMBODIMENT

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Operations of an exemplary arc-seeded microwave plasma torch such as those described in § 4.2.1 above, are described in § 4.3.1 below. Operations of an exemplary system generating two (or more) microwave torches simultaneously, such as those described in § 4.2.2 above, are described in § 4.3.2 below.

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§ 4.3.1 OPERATIONS OF AN EXEMPLARY ARC-SEEDED MICROWAVE PLASMA TORCH

The operation of an exemplary microwave torch involves the operation of the

5   torch module and the operation of the magnetron. Both components may be run at a 60

Hz periodic mode. The circuit arrangement shown in Figure 4 keeps the arc discharge in

synch with the microwave discharge in each cycle. The resistor 460 of 750 Ω in the

circuit may be chosen to achieve an optimal operating condition in which the arc

discharge pulse overlaps with the microwave pulse and also starts right at the beginning

10   of the microwave pulse.

Two digital oscilloscopes provided four channels to simultaneously measure the

time varying voltages and currents of the arc discharge of the torch module and of the

magnetron. The V-I characteristics and power functions of the arc discharge and

magnetron input in the case of gas flow rate at 1.133 l/s are presented in Figures 10 and

15   11, respectively. As shown in Figure 10, the breakdown voltage of the arc discharge is

about 3.5 kV and the peak arc current is about 4A. The magnetron has a starting voltage

of about 4 kV and an operating current of about 1A. As indicated by the power functions

in Figure 11, the magnetron starts operation before the arc discharge. However,

microwave generation is disrupted by the appearance of the arc discharge and restarts

20   right after the peak of the arc discharge. This disruption on the operation of the

magnetron is because the capacitors in the circuit cannot effectively ballast the

perturbation from the arc discharge on the voltage applied to the magnetron. This

disruption could be avoided by using two separate transformers. However, since the arc

discharge pulse is much shorter than the microwave pulse, this disruption does not

25   significantly degrade the performance of the magnetron. Under the influence of arc

discharge, the microwave pulse (inferred by the input power of the magnetron shown in

Figure 11) becomes shorter but the power becomes higher.

The cycle energies of the arc discharge and magnetron input as function of the gas

flow rate f are presented in Figure 12. As shown, the effect of the gas flow saturates at a

30   rate exceeding 0.393 l/s. In that flow rate regime, the cycle energy of the torch plasma

reaches the maximum of about 12 J (assuming that magnetron has 50% conversion

efficiency).

§ 4.3.2 OPERATION OF AN EXEMPLARY SYSTEM INCLUDING TWO OR MORE MICROWAVE PLASMA TORCHES

5   The two-torch system with the embodiment described in § 4.2.2 utilizes a single microwave source. The arc discharges in the two torch modules are synchronized with the same microwave pulse in the operation. Thus two separate power supplies may be used in this system. One may be identical to the one shown in Figure 4, which runs the magnetron and one of the two torch modules. The other torch module may be run by a

10   separate power supply. The same 60 Hz power line synchronizes the output voltages of two power supplies. Since the arc discharges do not affect each other, the electrical characteristics of each torch module are similar to that presented in Figures 10 and 11. The microwave power used to generate the two microwave torches shown in Figure 7B is provided by two magnetron outputs combined by a microwave combiner (Magic Tee).

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§ 4.4 CONCLUSIONS

          By combining a plasma torch with a microwave generator, an arc plasma torch may be used to seed a microwave discharge to produce a large, high density, plasma

20   torch, without requiring gas flow.

          Without seeding, the moderate microwave power of the magnetron (e.g., ~700W) would be too low to initiate microwave discharge by itself in a low Q cavity. Therefore, the present invention has the advantage of triggering microwave discharge and producing a large high density plasma discharge (torch) using a low Q cavity at a moderate

25   microwave power level.

          Such a new hybrid arc/microwave plasma torch, may be constructed from parts of commercially available microwave ovens, spark plugs, and a tapered cavity. The size of the torch is nearly doubled by doubling the diameter of this opening from that of the torch module. This hybrid arc/microwave plasma torch has a peak plasma density exceeding

30   10^{13} electrons/cm^3 and can achieve a volume of approximately 20 cc without applying a very large airflow.